Supporting Information for

Photocatalytic nitrogen fixation of metal-organic frameworks (MOFs) excited by

ultraviolet light: Insights into the nitrogen fixation mechanism of missing metal

cluster or linker defects

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Figure S1. The cyclic voltammetry (CV) curves patterns of (a) UiO-66-fresh and (b) UiO-66-UV-vis at the scan rates range from 20 to 120 mV/s.

In the typical ECSA test, the surface area of a material is analyzed rely on electrochemical double layer capacitance (C_{dl}), which could be performed by cyclic voltammetry (CV). Therefore, the C_{dl} values were derived from CV curves using the halves of the positive current density differences at the center point of their potential ranges.



Figure S2. (a) SEM images and (b) TEM images of UiO-66-UV-vis.



Figure S3. The photo of (a) UiO-66-fresh and (b) UiO-66-UV-vis.



Figure S4. High performance liquid chromatography (HPLC) spectrum of the first photocatalytic solution.



Figure S5. Standard titration method for determination of HCO_3^- or CO_3^{2-} : (a) adding phenolphthalein indicator (colorless), (b) not adding hydrochloric acid (colorless), (c) adding methyl orange indicator (orange-yellow), and (d) adding hydrochloric acid (orange-red).



Figure S6. XRD and UV-vis DRS of UiO-66-UV-vis-ethanol and UiO-66-fresh.



Figure S7. (a) UV-Vis absorption curves of different concentrations of NH_4^+ ions tested by Nessler's reagent method, (b) A calibration curve used to estimate the concentrations of NH_4^+ ions.

The fitting curve (y = 0.1544x + 0.009, R²= 0.999) shows good linear relationship between the absorbance value and the NH₄⁺ concentration.



Figure S8. (a) Ion chromatograms of NH_4^+ with different concentrations in ultrapure water, (b) A calibration curve, (c) Ion chromatogram data for the solution at different light irradiation under N_2 ambient potentials, and (d) NH_3 yields calculated by ion chromatography.



Figure S9. NH₄⁺ production rate of activated UiO-66 along with the reaction time.



Figure S10. (a) UV-Vis absorption curves of various concentrations of N_2H_4 stained with p-C₉H₁₁NO indicator, (b) A calibration curve used to estimate the concentrations of N_2H_4 .

The fitting curve (y = 1.6331x + 0.0187, R²= 0.999) shows a good linear relation of absorbance value with N₂H₄ concentration.



Figure S11. UV-Vis absorption spectra of the solution stained with $p-C_9H_{11}NO$ indicator after photocatalytic nitrogen fixation different time.



Figure S12. (a) N_2 adsorption-desorption isotherms, (b) Plot of the scan rates against the differences in the double layer charging current, (c) UV-vis DRS, and (d) Tauc plots of UiO-66-UV-vis-1st and UiO-66-UV-vis-5th.



Figure S13. The cyclic voltammetry (CV) curves patterns of (a) UiO-66-UV-vis-1st and (b) UiO-66-UV-vis-5th at the scan rates range from 20 to 120 mV/s.

The calculation process is the same as Figure S1.



Figure S14. Electrochemical impedance spectra (EIS) of UiO-66-fresh and UiO-66-

UV-vis-5th	under	dark	and	light	conditions.
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Figure S15. (a) Linear sweep voltammetry (LSV) spectra of the UiO-66 under dark condition and 300 W Xenon light irradiation in N_2 ambient, and (b) Photocurrent spectra of UiO-66-fresh and UiO-66-UV-vis-5th.

Before the photocurrent measurements, the linear sweep voltammetry test was conducted under dark condition and 300 W Xenon light irradiation in N_2 ambient to determine the bias voltage was 0.7 V.



Figure S16. N₂-TPD spectra of UiO-66-fresh, UiO-66-UV-vis-1st, and UiO-66-UV-

vis-5th.



Figure S17. (a) N_2 adsorption-desorption isotherms, and (b) pore size distribution curves of UiO-66-fresh and UiO-66-UV-vis-5th and UiO-66-PSE.



Figure S18. The UV-vis diffuse reflectance spectra (UV-vis DRS) of UiO-66-UV-

vis-5th

and

UiO-66-PSE.



Figure S19. XRD pattern of UiO-66-ideal.



Figure S20. (a) Scanning electron microscopy (SEM) images and (b) Transmission

electron microscopy (TEM) images of UiO-66-ideal.

Distant inter	Surface area	Mean pore diameter	Total pore volume	
Photocatalysi	$(m^2 \cdot g^{-1})$	(nm)	$(cm^{3} \cdot g^{-1})$	
UiO-66-fresh	995	2.12	0.416	
UiO-66-UV-vis	1225	2 77	0.510	
(UiO-66-UV-vis-1st)	1225	2.77	0.319	
UiO-66-UV-vis-5th	1144	2.82	0.493	
UiO-66-ideal	819	2.10	0.388	

Table S1 Comparison of physical properties of the samples

Photocatalyst	Reaction medium	Scavenger	Light source	Nitrogen source	NH3 yield	Reference	
	H ₂ O	No	UV-vis	N_2	256 μmol g ⁻¹ h ⁻¹		
UiO-66				Air	196 µmol g ⁻¹ h ⁻¹	This work	
			λ≥ 420	N_2	97 μmol g ⁻¹ h ⁻¹	I IIIS WOLK	
			nm	Air	70 µmol g ⁻¹ h ⁻¹		
Ti ₃ C ₂ -QD/Ni- MOF	H ₂ O+ NaSO ₃	1 mM NaSO3	UV-vis	N ₂	88.79 μmol g ⁻¹ h ⁻¹	1	
MIL-53 (Fe II/Fe III)	H ₂ O+ K ₂ SO ₃	0.158 g/L K ₂ SO ₃	λ≥ 420 nm	N ₂	306 µmol g ⁻¹ h ⁻¹	2	
Gd-IHEP-7					128 μmol g ⁻¹ h ⁻¹		
Gd-IHEP-8	H ₂ O	No	UV-vis N	N ₂	220 μmol g ⁻¹ h ⁻¹	3	
g-C ₃ N ₄ /MOF-74 (Zn)	H ₂ O+ Methanol	Methanol (4% wt)	λ≥ 400 nm	Air	1.7 mmol g ⁻¹ h ⁻¹	4	
MIL-101 (Fe)	H ₂ O	No	UV-vis	N ₂	100 μmol g ⁻¹ h ⁻¹	5	
NH ₂ -MIL-125 (Ti)	H ₂ O	No	λ≥ 400 nm	N ₂	12.25 μmol g ⁻¹ h ⁻¹	6	
Ce-MOF	H ₂ O	No	UV-vis	N ₂	34 µmol g ⁻¹ h ⁻¹	7	

 Table S2 Comparison of nitrogen photofixation rate with various MOF photocatalysts

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